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AMENDMENTS TO THE CLAIMS:

Please amend the claims as follows:

1. (Currently amended) An integrated circuit comprising:

a first array of memory cells, each memory cell in the first array comprising a resistive element and a Schottky diode coupled in series and having first and second terminals, the resistive element being formed by a single layer of material, the Schottky diode being formed by two layers, the single layer for the resistive element and the two layers for the Schottky diode being stacked together;

a first plurality of bit lines, one bit line for each column of the first array, each bit line coupled to the first terminal of memory cells in a respective column of the first array; and

a first plurality of word lines, one word line for each row of the first array, each word line coupled to the second terminal of memory cells in a respective row of the first array.

- 2. (Currently amended) The integrated circuit of claim 1, wherein the resistive element for each memory cell is formed by a film of a perovskite material.
- 3. (Original) The integrated circuit of claim 2, wherein the perovskite material is Pr_{0.7}Ca_{0.3}MnO₃.
- 4. (Original) The integrated circuit of claim 2, wherein the perovskite material is a colossal magnetoresistive (CMR) material.
- 5. (Currently amended) The integrated circuit of claim 1, wherein the two layers for the Schottky diode for each memory cell is formed by a thin film comprise a layer of amorphous silicon.
- 6. (Original) The integrated circuit of claim 1, wherein a memory cell is formed at each cross point between a bit line and a word line.

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7. (Original) The integrated circuit of claim 1, wherein the resistive element for each memory cell is programmable to have one of two resistance states.

- 8. (Original) The integrated circuit of claim 1, further comprising:
 a bit line driver operative to drive the first plurality of bit lines for reading
 and programming the memory cells.
- 9. (Original) The integrated circuit of claim 1, further comprising: a word line decoder operative to drive the first plurality of word lines for reading and programming the memory cells.
- 10. (Original) The integrated circuit of claim 1, further comprising: a plurality of sense amplifiers coupled to the first plurality of bit lines, each sense amplifier operative to sense a current on a respective bit line to determine a resistance state of a resistive element for a memory cell selected for reading.
- 11. (Original) The integrated circuit of claim 1, further comprising:
 a second array of memory cells, each memory cell in the second array
 comprising a resistive element and a Schottky diode coupled in series and having first and
 second terminals;

a second plurality of bit lines, one bit line for each column of the second array, each bit line coupled to the first terminal of memory cells in a respective column of the second array; and

a second plurality of word lines, one word line for each row of the second array, each word line coupled to the second terminal of memory cells in a respective row of the second array.

12. (Currently amended) A memory device comprising:

an array of memory cells, each memory cell comprising a resistive element and a Schottky diode coupled in series and having first and second terminals, the resistive element being formed by a single layer of material, the Schottky diode being formed by

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two layers, the single layer for the resistive element and the two layers for the Schottky diode being stacked together;

a plurality of bit lines, one bit line for each column of the array, each bit line coupled to the first terminal of memory cells in a respective column of the array;

a plurality of word lines, one word line for each row of the array, each word line coupled to the second terminal of memory cells in a respective row of the array;

a bit line driver operative to drive the plurality of bit lines for reading and programming the memory cells;

a word line decoder operative to drive the plurality of word lines for reading and programming the memory cells; and

a plurality of sense amplifiers coupled to the plurality of bit lines, each sense amplifier operative to sense a current on a respective bit line to determine a resistance state of a resistive element for a memory cell selected for reading.

- 13. (Currently amended) The memory device of claim 12, wherein the resistive element for each memory cell is formed by a film of a perovskite material.
- 14. (Currently amended) The memory device of claim 12, wherein the two layers for the Schottky diode for each memory cell is formed by a thin film comprise a layer of amorphous silicon.
- 15. (Withdrawn) A method of fabricating a resistive memory, comprising:

forming a first plurality of word lines, one word line for each row of a first memory array;

forming a first plurality of memory cells for the first memory array, each memory cell comprising a film of a perovskite material for a resistive element and a thin film of amorphous silicon for a Schottky diode; and

forming a first plurality of bit lines, one bit line for each column of the first memory array, wherein each word line is coupled to a first terminal of memory cells in a respective row of the first memory array, and wherein each bit line is coupled to a second terminal of memory cells in a respective column of the first memory array.

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16. (Withdrawn) The method of claim 15, wherein the perovskite material is Pr_{0.7}Ca_{0.3}MnO₃.

17. (Withdrawn) The method of claim 15, further comprising: forming a second plurality of word lines, one word line for each row of a second memory array;

forming a second plurality of memory cells for the second memory array, each memory cell comprising a film of a perovskite material for a resistive element and a thin film of amorphous silicon for a Schottky diode; and

forming a second plurality of bit lines, one bit line for each column of the second memory array, wherein each word line is coupled to a first terminal of memory cells in a respective row of the second memory array, and wherein each bit line is coupled to a second terminal of memory cells in a respective column of the second memory array.

18. (Withdrawn) A method of reading a selected memory cell in a resistive memory comprising a plurality of memory cells, each memory cell including a resistive element and a Schottky diode coupled in series, the method comprising:

providing a reverse bias voltage across each memory cell not selected for reading;

providing a forward bias voltage across the selected memory cell; and sensing a current from the selected memory cell to determine a resistance state of the resistive element for the selected memory cell.

19. (Withdrawn) A method of programming a selected memory cell in a resistive memory comprising a plurality of memory cells, each memory cell including a resistive element and a Schottky diode coupled in series, the method comprising:

providing a reverse bias voltage across each memory cell not selected for programming; and

providing one or more electric pulses with a forward bias voltage across the selected memory cell.

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- 20. (Withdrawn) The method of claim 19, wherein the resistive element for the selected memory cell is programmed to a high resistance state with one or more electric pulses of a first amplitude and a first width and programmed to a low resistance state with one or more electric pulses of a second amplitude and a second width.
- 21. (Withdrawn) The method of claim 20, wherein the first amplitude is higher than the second amplitude and the first width is shorter than the second width.
- 22. (Previously presented) The integrated circuit of claim 11, further comprising:

an isolation layer between a first layer and a second layer, wherein the first layer is formed by the first array of memory cells, the first plurality of bit lines, and the first plurality of word lines, and wherein the second layer is formed by the second array of memory cells, the second plurality of bit lines, and the second plurality of word lines.

23. (Withdrawn) An integrated circuit comprising an array of memory cells, each memory cell in the array comprising:

a resistive element formed by a film of a perovskite material, and a Schottky diode coupled in series with the resistive element and formed by a film of amorphous silicon (a-Si) and a film of doped amorphous silicon (N+ a-Si).

24. (Withdrawn) The integrated circuit of claim 23, wherein each memory cell in the array further comprises

a metal layer disposed between the resistive element and the Schottky diode.